Device simulation of perovskite solar cells with molybdenum disulfide as active buffer layer

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ABSTRACT

Organo-halide Perovskite Solar Cells (PSCs) have been reported to achieve remarkably high power conversion efficiency (PCE). A thorough understanding of the role of each component in solar cells and their effect as a whole is still required for further improvement in PCE. In this paper, the effect of Molybdenum Disulfide (MoS₂) in PSC with mesoporous structure configuration was analyzed using Solar Cell Capacitance Simulator (SCAPS). With the MoS₂ layer which having two-fold function, acting as a protective layer, by preventing the formation of shunt contacts between perovskite and Au electrode, and as a hole transport material (HTM) from the perovskite to the Spiro-OMETAD. As simulated, PSC demonstrates a PCE, of 13.1%, along with stability compared to typical structure of PSC without MoS₂ (Δŋ/ŋ=−9% vs. Δŋ/ŋ=−6%). The results pave the way towards the implementation of MoS₂ as a material able to boost shelf life which very useful for new material choice and optimization of HTMs.

Keywords: Active layer Device simulation MoS₂ Perovskite Solar cells

1. INTRODUCTION

Solid-state organo-metal halide perovskite solar cells (PSCs) have been developed as promising alternatives to existing solution-processed photovoltaic technologies [1-4]. The methylammonium iodide, M₅I (CH₃NH₃PbI₃) is one of the most ample light-harvesting material, mainly due to its direct bandgap, high absorption coefficient and long exciton diffusion length [5]. Despite the impressive photovoltaic performance with power conversion efficiency (PCE) beyond 22%, PSCs’ operational stability and the material toxicity is endure the crucial concern.

To achieve higher efficiency, the understanding of device mechanism is important. Due to this reason, device simulation is useful and brought the conventional solar cells based on inorganic semiconductor such as silicon, CdTe, Cu(In, Ga)Se₂ (CIGS) and Cu₂SnZn (S,Se₄) were widely analysed using device simulator [6–9]. Up to now, there are a few reports been concerning on the numerical simulation of the perovskite-based solar cells [10-12]. However, the detailed theoretical analysis of the stability of PSCs using device simulation is not extensively studied. The perovskite material are organic-inorganic hybrid materials and have similar material properties with inorganics materials especially low binding energy of exciton, and thus the exciton is Wannier type. Also, the device structure of the PSCs and inorganics thin film
solar cells is similar. The typical structure for the PSCs is TCO/BL/absorber/HTM/contact and that of CIGS solar cells is TCO/buffer/absorber/contact.

A further substantial limitation on view of the possible commercialization is their lifetime stability which adversely affected by the presence of the Spiro-OMEDTAD [13]. This is due to the fact that Spiro-OMEDTAD in its pristine form (amorphous), which has low conductivity, σ [14]. Another factor limiting the device stability is the interface created by the Spiro-OMEDTAD and the perovskite layer [12-13]. Analysis done by [15] reported indication of iodine migration from the perovskite layer to Spiro-OMEDTAD and degraded the cell efficiency. Slow transient effects causing hysteresis in the current-voltage characterization can lead to an over-or underestimation of the solar cell device efficiency [16]. Subsequent, the direct contact between the perovskite and the metal electrode shows the high recombination losses which decreased the open-circuit voltage, Voc and Fill Factor value [17]. One strategy to minimize the effect could be to increase the hole transport layer thickness, however it will results in increasing the PSCs series resistance, which reduced the cell efficiency [18]. The addition of mesoporous Aluminium oxide, Al₂O₃ layer in between the perovskite and Spiro-OMEDTAD to prevent shunting pathway as a passive protection function [19].

2. METHOD

In this paper, device simulation are performed by using Solar Cell Capacitance Simulator (SCAPS). The device simulator, SCAPS was developed by University of Gent [20] and it is used to model the PSCs. MoS₂ layer is inserted in PSCs with FTO/TiO₂/CH₃NH₃PbI₃/Spiro-OMETAD structure to create an active buffer layer. There will be a two functions of this layer which are barrier towards the metal electrode migration and additional energy matching layer for the further ease the hole collection of the Spiro-OMEDTAD. First, the validity of device modelling was confirmed by the comparison with real device. Then, the insertion of MoS₂ layer in between the perovskite and Spiro-OMEDTAD was modelled to examine the stability of the PSCs. Device characteristics under various condition can be studied through theoretical analysis of solar cell.

3. DEVICE SIMULATION PARAMETERS

The device simulator SCAPS Version 3.3.07 was used as a simulation platform. PSCs employed in the simulation is a solid-state n-i-p structure with intrinsic perovskite material sandwiched between n-type TiO₂ and p-type Spiro-OMeTAD (2,2',7,7'- tetrakis (N,N-di-p-methoxyphenylamine) -9,9’ spirobifluorene) material. Spiro-OMEDTAD is applied as the hole transport material (HTM). SnO₂:F (FTO) is the transparent conductive oxide (TCO) and Au serves as a contact as shown in Figure 1(a). Figure 1(b) it shows the structure with MoS₂ layer in between perovskite and Spiro-OMEDTAD. Compared to the typical structure, two hypothetical interface defect layers, i.e. TiO₂/perovskite layer (IDL1) and perovskite/HTM layer (IDL2), are inserted into the model to consider the recombination on the interfaces. Note that some parameters are very difficult to determine, thus, some reasonable value was estimated. For all layers, the effective density of states of conduction band Nₑ, the effective density of states of valence band Nᵥ, and the thermal velocity, Nₜ, are set as 2.2×10¹⁸ cm⁻³, 1.8×10¹⁹ cm⁻³ and 10⁷ cm/s, respectively. The absorption coefficient is set to be 10⁵ cm⁻¹ to simplify the model. Defect type is neutral and the capture cross section is 2×10⁻¹⁴ cm².

![Figure 1](image_url)

Figure 1. Device structure, (a) FTO/TiO₂/CH₃NH₃PbI₃/Spiro OMEDTAD, (b) FTO/TiO₂/CH₃NH₃PbI₃/MoS₂/Spiro-OMEDTAD
Table 1 summarizes the base parameter set of each layer in simulation. Here, NA and ND denote acceptor and donor densities, $\varepsilon_r$ is relative permittivity, $\chi$ is electron affinity, $E_g$ is band gap energy, $\mu_n$ and $\mu_p$ are mobility of electron and holes. The thickness of each layer were taken from an experimental that report high efficiency PSCs [21]. Pre-factor $A_\alpha$ was 105 to obtain absorption coefficient $\alpha$ calculated by $\alpha=A_\alpha (h\nu-E_g)^{1/2}$. Energetic distribution is Gaussian, and the characteristic energy is set to be 0.1 eV. The default illumination spectrum is set to the global AM1.5 standard and the default operation temperature is set to 300K. The optical reflectance at the surface and interfaces of each layer is not considered in this work. The validity of the device simulation is to compared and confirmed with the real devices performance reported by literature to demonstrate the reliability. With the default parameters, we get the result of $J_{sc}=21.68$ mA/cm$^2$, $V_{oc}=0.97$ V, $FF=0.66$ and $PCE=13.93\%$, which is similar with the experimental results reported in literature [22].

<table>
<thead>
<tr>
<th>Parameter</th>
<th>FTO</th>
<th>TiO$_2$</th>
<th>IDL1</th>
<th>CH$_3$NH$_3$PbI$_3$</th>
<th>IDL2</th>
<th>HTM</th>
</tr>
</thead>
<tbody>
<tr>
<td>Thickness (nm)</td>
<td>500</td>
<td>50</td>
<td>10</td>
<td>350</td>
<td>10</td>
<td>400</td>
</tr>
<tr>
<td>Bandgap, $E_g$(eV)</td>
<td>3.5</td>
<td>3.2</td>
<td>1.55</td>
<td>1.55</td>
<td>1.55</td>
<td>3</td>
</tr>
<tr>
<td>Electron affinity, $\chi$(eV)</td>
<td>4</td>
<td>4</td>
<td>3.9</td>
<td>3.9</td>
<td>3.9</td>
<td>2.05</td>
</tr>
<tr>
<td>Dielectric permittivity, $\varepsilon_r$</td>
<td>9</td>
<td>100</td>
<td>6.5</td>
<td>6.5</td>
<td>6.5</td>
<td>3</td>
</tr>
<tr>
<td>$N_c$(cm$^{-3}$)</td>
<td>$2.2 \times 10^{18}$</td>
<td>$2.2 \times 10^{18}$</td>
<td>$2.2 \times 10^{18}$</td>
<td>$2.2 \times 10^{18}$</td>
<td>$2.2 \times 10^{18}$</td>
<td>$2.2 \times 10^{18}$</td>
</tr>
<tr>
<td>$N_v$(cm$^{-3}$)</td>
<td>$1.8 \times 10^{19}$</td>
<td>$1.8 \times 10^{19}$</td>
<td>$1.8 \times 10^{19}$</td>
<td>$1.8 \times 10^{19}$</td>
<td>$1.8 \times 10^{19}$</td>
<td>$1.8 \times 10^{19}$</td>
</tr>
<tr>
<td>Electron mobility, $\mu_n$(cm$^2$/Vs)</td>
<td>20</td>
<td>0.006</td>
<td>2</td>
<td>2</td>
<td>2</td>
<td>0.0001</td>
</tr>
<tr>
<td>Hole mobility, $\mu_p$(cm$^2$/Vs)</td>
<td>10</td>
<td>0.006</td>
<td>2</td>
<td>2</td>
<td>2</td>
<td>0.0001</td>
</tr>
</tbody>
</table>

4. RESULTS AND DISCUSSION

Devices such as solar cells, charge generation, disconnection and transportation actively contribute in the performance of the prepared perovskite solar cells. Therefore, engineering the energy band diagram, materials selection, and physical properties of materials would control the perovskite solar cells efficiency [23-25]. Figure 2 shows the structure of the prepared device from SCAPS simulation and the energy band diagrams of FTO/TiO$_2$/CH$_3$NH$_3$PbI$_3$/MoS$_2$/Spiro-OMeTAD. Device configuration shows in Figure 2(a) is the 3 nm compact layer of MoS$_2$, 350 nm perovskite layer, 50 nm TiO$_2$ thin film and the metal contact layer with 10 nm thickness. As shown in Figure 2(b) the generated electron can easily transfer to TiO$_2$ layer because of the high electron affinity of TiO$_2$ at the interface of TiO$_2$ and perovskite layer while MoS$_2$ layer can collect the generated holes.
4.1. Effect of the bandgap and thickness layer of the absorber

Figure 3 shows the variation of Voc, Jsc, FF and η depending on the bandgap energy of the perovskite layer. The PSCs with Eg=1.3, 1.4, 1.5 and 1.6 eV do not exhibit large differences in increasing Voc from 0.925V to 1.067V. However, Jsc, FF and η are found to be decreased with the increasing value of Eg. In detail comparison, Jsc decreased from 29.235 mA/cm$^2$ to 18.433 mA/cm$^2$, FF reduced from 83.65% to 59.87% meanwhile the η reduced from 22.63% to 11.78%.

![Graphs showing Voc, Jsc, FF, and PCE variation with Eg](image)

Figure 3. Variation of Voc, Jsc, FF and PCE depending on the bandgap energy of perovskite layer
Figure 4 shows the effect of the thickness of the perovskite layer on solar cell performance. For the structure with MoS$_2$, the optimum thickness of the perovskite layer is approximately 350 nm. At the thickness for the best J$_{sc}$, FF slightly decreased. For the typical structure without MoS$_2$, the optimum thickness is 500 nm. At the optimum thickness, the Voc and J$_{sc}$ are almost same for the both structures because of the current matching. However, FF shows the very large difference at the optimum perovskite layer thickness. In detail comparison with typical structure of PSCs, the cells with MoS$_2$ buffer layer show a decrease in Voc (0.969V vs. 0.982V) and FF (66.3% vs. 61.7%). However, J$_{sc}$ is found to remain unchanged 21.68 mA/cm$^2$ bringing the $\eta$ 13.13% from 13.93% of the cell without MoS$_2$.

![Graph showing the effect of thickness on performance](image)

**Figure 4.** The effect of thickness of the perovskite layer for both structure

The increasing thickness leads to more light absorption and more additional carrier concentration, which brings the values of J$_{sc}$ to elevate. Since perovskite material has very high absorption coefficient, normally up to $10^5$ cm$^{-1}$, the cell can achieve very high values of J$_{sc}$ and $\eta$ for very thin absorbers. V$_{oc}$ can be defined by (1):

$$V_{oc} = \frac{n kT}{q} \ln \left( \frac{I_s}{I_o} + 1 \right)$$

where $n$ is a factor, $kT/q$ is the thermal voltage, $I_s$ is the light generated current, and $I_o$ is the dark saturation current. More additional carriers concentration gives higher value of $I_s$, while $I_o$ stays at low level because of not much recombination in the cell. This is the reason why $V_{oc}$ increases initially.

The FF can be defined as the ability to deliver the available power to a load among the maximum power generated by a cell or the internal power reduction. Even though the $\eta$ is increasing with the thickness increasing when the thickness is less than 700nm, the internal power reduction is also increasing, causing a total decrease of the FF. The increase of $\eta$ is a compromise of weakening the power delivering ability. While the thickness is high, more and more recombination happens because of the increasing number of traps and because more and more additional carriers are not be able to reach the electrodes. In this case, thicker absorber brings the FF, $V_{oc}$ and $\eta$ to decrease. Thus, it can be concluded in this simulation, the performance...
of a solar cell is controlled by two factors, photon absorption and carrier transport. Photon absorption is the determinant for thin absorber and carrier transport is the determinant for thick absorber, the Save As command, and use the naming convention prescribed by your conference for the name of your paper. In this newly created file, highlight all of the contents and import your prepared text file. You are now ready to style your paper; use the scroll down window on the left of the MS Word Formatting toolbar.

4.2. Effects of the interface defect density

The intersection quality of the interface layers is very important to the cell performance. The defect layers might degrade the quality and cause high recombination. Due to the difficulty in approximation of the recombination caused by the interface defects, the hypothetical defect layers are inserted to represent the interface defects. IDL1 stands for TiO$_2$/perovskite interface and IDL2 stands for perovskite/HTM interface. The defect densities can determine the recombination on the interfaces. In the simulation, the defect density of IDL1 and IDL2 was varied from $10^{13}$ to $10^{21}$ cm$^{-3}$, respectively. Other parameters remain default. The results are shown in Figure 5.

![Figure 5. Different defect densities in the conditions of, (a) changing IDL1, and (b) changing IDL2](image)

The results show that the defect density on the TiO$_2$/perovskite interface affects strongly on the performance (higher values of $J_{SC}$, $V_{OC}$ and PCE at lower defect density levels). Equally, the defect density on the perovskite/HTM interface has mild impact on the performance. The increase of defect density will certainly increase the number of traps in the cells, which will cause more recombination, and then the performance will become worse. However, the effect of IDL1 is much stronger than IDL2, the reason is that under illumination, the number of electron-hole pairs generated at the irradiation side (front side) of absorber are much higher (reaching ten times) than that at the back side. That is, the additional carrier density is higher at front side, leading to greater recombination rate on front interface. Therefore, the front interface (TiO$_2$/perovskite) has stronger influence on device performance than the back interface (perovskite/HTM). In this case, during the fabrication process of PSCs, it is better to focus on the TiO$_2$/perovskite interface instead of the perovskite/HTM interface, by improving the quality of the illuminating side interface to decrease the defect density and promote device performance.

4.3. Effect of MoS$_2$ layer

Table 2 shows the PV performance under different temperature for both structure. The performance of PSCs were further simulated with increasing operating temperature up to 350 K. These results shows better stability of the MoS$_2$-based with respect to the basic structure. The MoS$_2$-based PSC shows a decrease in the efficiency which from 13.13% to 12.28% ($\Delta\eta/\eta$=-6%) compared to reference cell which degraded from 13.93% to 12.67% ($\Delta\eta/\eta$=-9%). The improved stability of the MoS$_2$-based is endorsed to the surface passivation of the perovskite layer provided by MoS$_2$ which prevents the iodine migration from the perovskite into the Spiro-OMETAD and the formation of Au from the metal electrode to perovskite layer. Figure 6(a) shows the quantum efficiency (QE) curves for both structure which indicated the MoS$_2$-based cell has a slightly high value in the 350-700nm range compared to the reference cell. Meanwhile, Figure 6(b) shows the Nyquist plot of the PSCs. The arcs at high-intermediate frequency are mainly attributed to the charge-transport resistance, (Rct) at the interface of FTO contact with the perovskite layer.
Table 2. PV performance under different temperature

<table>
<thead>
<tr>
<th>Structure</th>
<th>T=300 K</th>
<th>T=350 K</th>
</tr>
</thead>
<tbody>
<tr>
<td>FTO/TiO₂/CH₃NH₃PbI₃/Spiro-OMETAD</td>
<td></td>
<td></td>
</tr>
<tr>
<td>$V_{oc}$ (V)</td>
<td>0.969</td>
<td>0.869</td>
</tr>
<tr>
<td>$J_{sc}$ (mA/cm²)</td>
<td>21.676</td>
<td>21.324</td>
</tr>
<tr>
<td>FF (%)</td>
<td>66.295</td>
<td>68.388</td>
</tr>
<tr>
<td>$\eta$ (%)</td>
<td>13.93</td>
<td>12.67</td>
</tr>
<tr>
<td>$V_{oc}$ (V)</td>
<td>0.983</td>
<td>0.870</td>
</tr>
<tr>
<td>FTO/TiO₂/CH₃NH₃PbI₃/MoS₂/Spiro-OMETAD</td>
<td></td>
<td></td>
</tr>
<tr>
<td>$J_{sc}$ (mA/cm²)</td>
<td>21.676</td>
<td>21.324</td>
</tr>
<tr>
<td>FF (%)</td>
<td>61.650</td>
<td>66.200</td>
</tr>
<tr>
<td>$\eta$ (%)</td>
<td>13.13</td>
<td>12.28</td>
</tr>
</tbody>
</table>

5. CONCLUSION

The simulation results show that due to the high absorption coefficient, absorber layer up to 700nm is sufficient for decent performance device, and there is an optimal thickness for most certain operating condition. The use of MoS₂ layer as an active layer has been demonstrated in hybrid lead halide perovskite solar cells with FTO/TiO₂/CH₃NH₃PbI₃/MoS₂/Spiro-OMETAD structure. Typical structure of PSCs without MoS₂ have shown a $\eta$ of 13.9% diminishing to 12.6% at different temperature condition. MoS₂-based PSCs instead

Figure 6. Quantum efficiency (QE) curves for both structure, (a) Nyquist plot with the basic parameters in Table 1, (b) Quantum efficiency characteristics
reached a $\eta$ of 13.1% decreased to 12.3%, proving the enhanced stability of the cell due to the presence of MoS$_2$ layer as active layer. The results pave the way towards the implementation of MoS$_2$ as a material able to boost shelf life which very useful for new material choice and optimization of HTMs.

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